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		APPLICANT: Luc WUIDART et al.			
		GROUP ART UNIT: Unassigned ²⁸¹⁶		EXAMINER: Unassigned ^{Wambach}	
Sheet	1	of	1		

U.S. PATENT DOCUMENTS

Examiner's Initials	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication or of issue of Cited Document MM-DD-YYYY
		Number	Kind Code		
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MRW	*	5,418,738		Abadeer et al.	05/23/95
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Examiner's Initials	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document (not necessary)	Date of Publication of Cited Document MM-DD-YYYY	Translation (Y/N)
		Office/Country	Number	Kind Code			
MRW		DE	101 01 575	A1	Infineon Technologies AG	07/25/02	N

OTHER ART — NON PATENT LITERATURE DOCUMENTS

Examiner's Initials	Cite No	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)
		French Search Report from French Patent Application No. 02/13458, filed October 28, 2002	
		French Search Report from French Patent Application No. 02/13457, filed October 28, 2002	
		French Search Report from French Patent Application No. 02/13694, filed October 31, 2002	
		Kato K. et al. "A Physical Mechanism of Current-Induced Resistance Decrease In Heavily Doped Polysilicon Resistors" IEEE Transactions on Electron Devices, IEEE Inc. New York, US, vol. 29, no. 8, August 1982, pages 1156-1161	

EXAMINER ^{Wambach}	DATE CONSIDERED ^{7/10/04}
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